## **OAI Backside Alignment Procedure**

- 1. Load mask and substrate then calibrate per frontside procedure.
- 2. Unload substrate until ready to process in step 10.
- 3. Change Process Settings:
  - a) Process mode Backside Alignment
  - b) Exposure time
  - c) Gap
- 4. Switch to Bottom Optic by flipping the toggle switch on the left side of the tool.
- 5. Turn on monitors and set-up tool for bottom-side alignment.
  - a) Unlock monitors by pushing "LOCK" on the panel until "UNLOCK" disappears from the screen.
  - **b)** Select Camera "2 ONLY" on the console. It will display in upper left corner of the monitor.
  - c) Change reticle by selecting "MODE" until desired reticle appears.
- **6.** Focus on Mask by using focus controls left and right on front of tool. Adjust illumination as needed. Make sure optics are within the alignment windows. Use X & Y axis controls to move optics.
- 7. Align mask by using X & Y axis controls to place alignment marks in desired position on the monitors.
- 8. Move lamp housing to Expose Position in "Manual Test" page on LCD screen.
- 9. Align reticles to alignment marks on monitors using DVPG console for each monitor:
  - a) Select 1 or 2 for desired reticle line that you want to move.
  - **b)** The number selected will be displayed on lower right corner of the monitor.
  - c) Use the  $\leftarrow \uparrow \rightarrow \downarrow$  arrows for proper placement of the reticle lines.
  - d) Repeat this until both X & Y reticle directions are where you want them.
- 10. Load substrate and apply substrate vacuum.
- 11. Level stage.
- 12. Focus on substrate using focus controls left and right on front of tool.
- **13.** Align substrate to reticles using micrometers on stage.
- **14.** Select level of contact needed and verify alignment.
- **15.** Select "CYCLE" when alignment is verified and you are ready for exposure.
- 16. Unload substrate once stage has unloaded.
- **17.** If you are running another wafer, continue from step 10.
- **18.** If you are finished, move lamp housing to Align Position in Manual Test page.
- 19. Unload your mask.
- 20. Default the tool back to Frontside operation by:
  - a) Monitor Place monitor back to Camera 1 ONLY.
  - b) Optics Flip toggle switch to bottom-side Optics.
  - c) Recipe Select Frontside in Process Mode in recipe.
  - d) X Axis Ensure the optics are moved out of the way to not hit the legs on the wafer chuck.
  - e) Focus Place Bottom Optic focus in the home position.

Carrie Sinclair 4/23/2013 Rev. A